



ITW/A.
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/712,775 Group Art Unit: 1765
Filing Date: November 14, 2003 Examiner: Anita K. Alanko
Applicant: Donggyun Han et al.
Title: APPARATUS AND METHOD FOR REMOVING
PHOTORESIST FROM A SUBSTRATE
Attorney Docket: 2557-000216/US

Customer Service Window December 29, 2005
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop Amendment

AMENDMENT

Sir:

In response to the Office Action mailed September 29, 2005, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

Amendments to the Claims begin on page 2 of this Amendment.

Remarks begin on page 8 of this Amendment.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	40	-	50	=	0
Independent	3	-	4	=	0